



Metal Titanium Sputtering Target Magnetron For LCD Screen CNC Machined

Our Product Introduction

Basic Information

- Place of Origin: China
- Brand Name: N/M
- Certification: ISO9001:2015 certification
- Model Number: CDX-TB-2021-012
- Minimum Order Quantity: 5 kg
- Price: Negotiable
- Packaging Details: plywood case
- Delivery Time: 5-35 working days
- Supply Ability: 50000KG/month



Product Specification

- Key Words: Titanium Target Sputtering Coating Titanium
- Name: Target Sputtering Coating Titanium
- Application: LCD Screen, Laser Memory, Coating
- Technique: Forged,CNC Machining,Hot Rolled,Forged And CNC Machined
- Grade: Gr1
- Density: 4.51g/cm3
- Key Words 2: Pure Titanium Target
- Highlight: **Magnetron Titanium Sputtering Target, LCD Screen Titanium Sputtering Target, CNC Machined Metal Sputtering Target**



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Product Description

Titanium Target Pure Metal Sputtering Target High Purity Metal Magnetron Sputter Target For PVD Coating High Purity Titanium target

High-purity and high-density sputtering targets include:

Sputtering target (purity: 99.9%-99.999%)

Titanium target plate

High-purity and high-density titanium sputtering target

Titanium target Titanium sputtering target material Used for liquid crystal display, laser memory, electronic controller, sputtering thin film material, semiconductor integrated circuit, solar photovoltaic, recording medium, flat display and surface coating of workpiece

Titanium target Titanium sputtering target material Used for liquid crystal display, laser memory, electronic controller, sputtering thin film material

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Titanium target titanium sputtering target is used for semiconductor integrated circuit, solar photovoltaic, recording medium, plane display and workpiece surface coating

Target Pure Metal Sputtering Target High Purity Metal Magnetron Sputter Target For PVD Coating High Purity

Titanium target with hole titanium target plate perforated

Material:	Pure titanium Gr. 1
Application:	Titanium target Titanium sputtering target material Used for liquid crystal display, electronic controller, sputtering thin film material, semiconductor integrated circuit, solar photovoltaic, recording medium, flat display and surface coating of workpiece
Purity:	99.96% - 99.99%
Custom made:	support
Tolerance:	+/-0.05mm
Shape:	round target, rectangular target

Usually we will provide a quality inspection report like this with the goods, which shows the chemical composition and physical properties

Terms of trade	EXW FOB CIF
Payment terms	T/T , L/C
packing	Plastic paper inside , plywood case outside
Delivery time	In general,the delivery time is 5 days to 35 days. Please confirm the exact delivery time with us as different products and different quantity need different delivery time.
MOQ	Small order quantity is acceptable







Q: Why choose us?

A1: We have 14 years experience for titanium products process.

A2: sample order is acceptable.

A3: lower price, good quality and short delivery time.

A4: The quotation can be made within 24 hours.

A5: ISO9001:2015 certification

A6: Give us drawing, make your drawings and ideas become a reality!

A7: Provide third-party quality inspection reports.

Sputtering targets are mainly used in the electronics and information industries, such as integrated circuits, information storage, liquid crystal displays, laser storage, electronic control devices, etc.; it can also be used in the field of glass coating; it can also be used in wear-resistant materials, high temperature and corrosion resistance, High-end decorative products and other industries.



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